

Supplementary Materials

Nanoflake NiMn Layered Double Hydroxide Coated on Porous Membrane-like Ni-Foam for Sustainable and Efficient Electrocatalytic Oxygen Evolution

Verjesh Kumar Magotra ¹, Arjun Magotra ², Sawanta S. Mali ³, H. C. Jeon ¹, T. W. Kang ¹, Amol S. Salunke ⁴, Chang Kook Hong ³, Nabeen K. Shrestha ⁴, Hyunsik Im ⁴ and Akbar I. Inamdar ^{4,*}

¹ Quantum-Functional Semiconductor Research Center, Dongguk University, Seoul, Republic of Korea

² Department of Computer Science and Engineering, Faculty of Engineering and Technology, Jain (Deemed-to-be University), Bengaluru 562112, India

³ Polymer Energy Materials Laboratory, School of Applied Chemical Engineering, Chonnam National University, Gwangju 500-757, Republic of Korea

⁴ Division of Physics and Semiconductor Science, Dongguk University, Seoul 04620, Republic of Korea

* Correspondence: akbarphysics@dongguk.edu

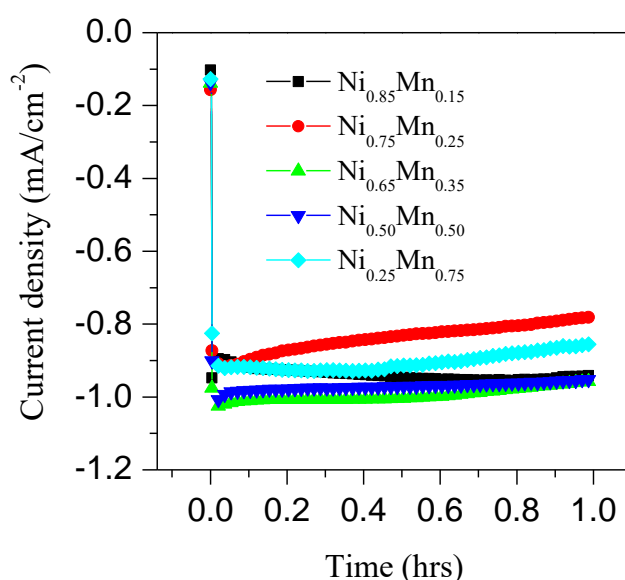


Figure S1. Chronoamperometric curves for the electrodeposition of the $\text{Ni}_{1-x}\text{Mn}_x$ LDH (where $x = 0.15, 0.25, 0.35, 0.50$ and 0.75) thin film electrodes.

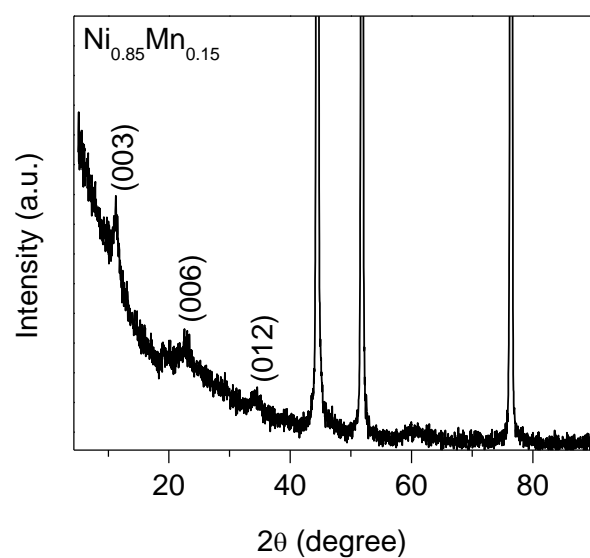


Figure S2. Typical XRD pattern of the $\text{Ni}_{0.65}\text{Mn}_{0.35}$ thin film electrode, with clear diffraction peak at 11.20° , 23.04° , and 34.46° suggesting formation of the NiMn LDH (JCPDS No. 38-0715) structure.

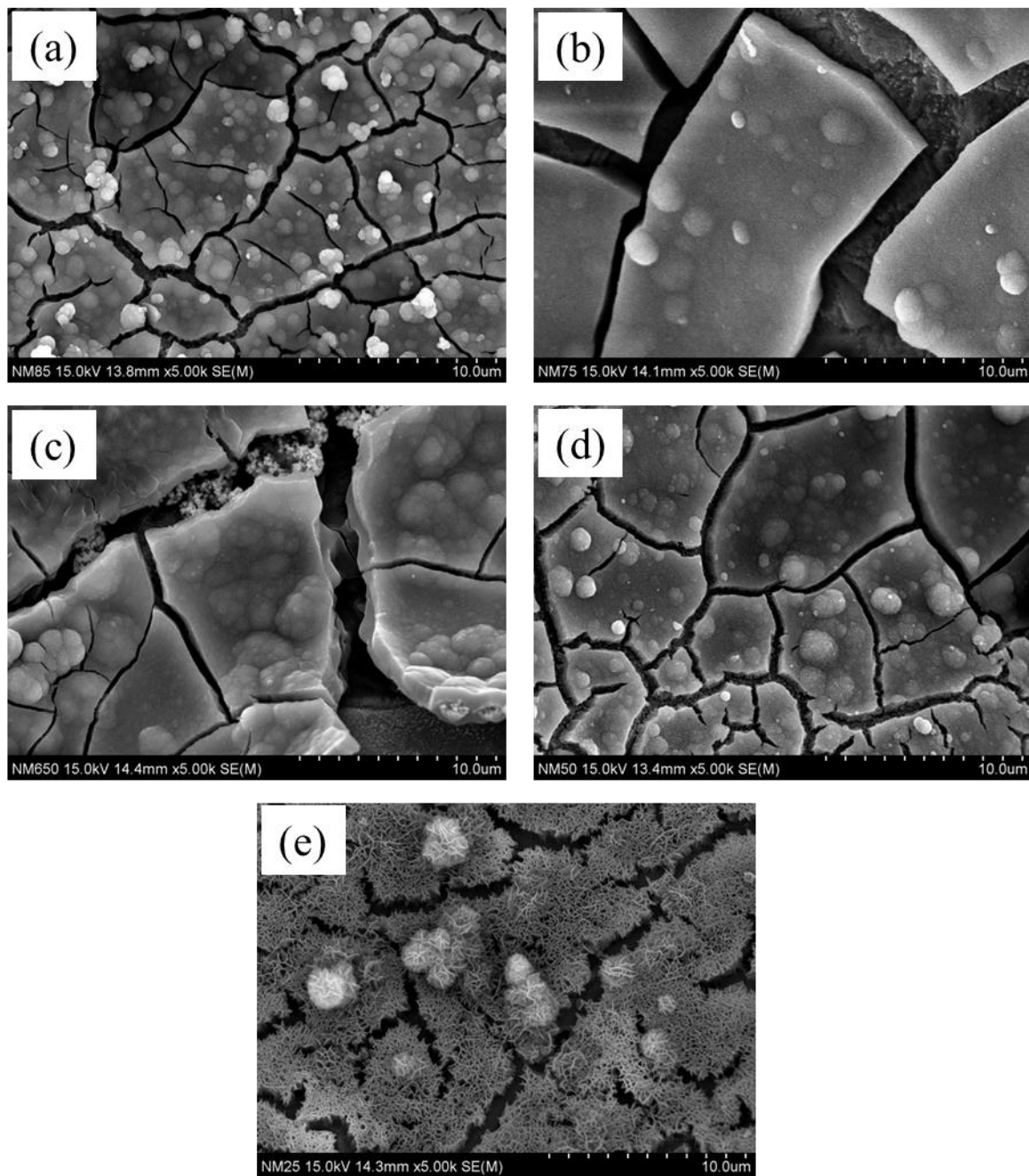


Figure S3. low magnification SEM images of the $\text{Ni}_{1-x}\text{Mn}_x$ LDH thin film electrodes. (a) $\text{Ni}_{0.85}\text{Mn}_{0.15}$, (b) $\text{Ni}_{0.75}\text{Mn}_{0.25}$, (c) $\text{Ni}_{0.65}\text{Mn}_{0.35}$, (d) $\text{Ni}_{0.50}\text{Mn}_{0.50}$ and (e) $\text{Ni}_{0.25}\text{Mn}_{0.75}$. All the samples showed the existence of the cracks in the sample.

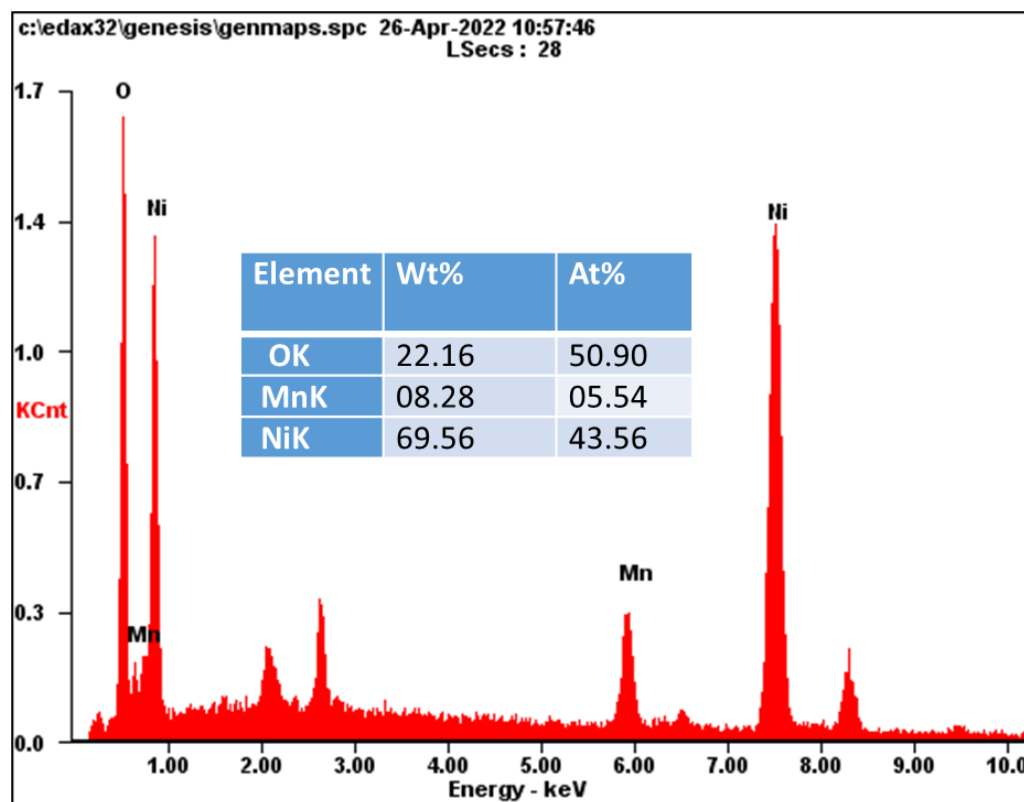


Figure S4. Energy dispersive X-ray analysis (EDX) of the NiMn LDH thin film catalyst to detect the elemental composition. It suggests the presence of the Ni, Mn, and O in the sample.

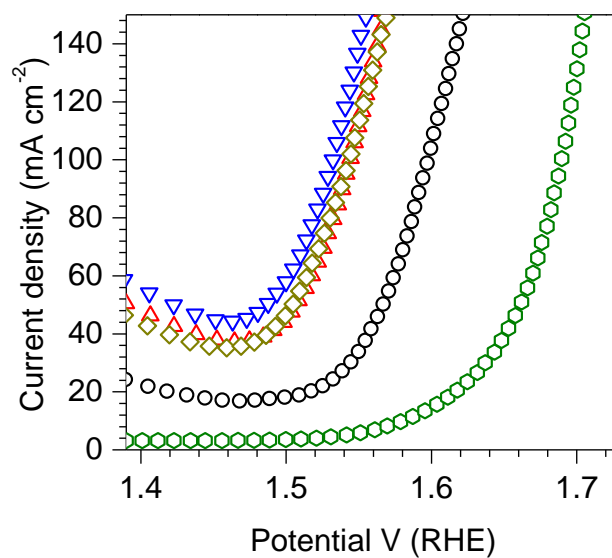
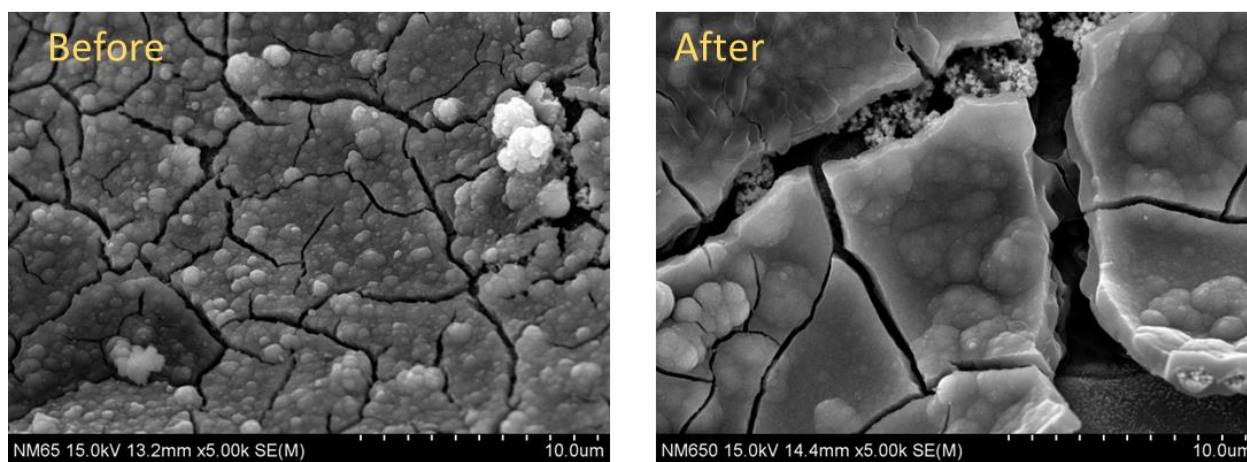


Figure S5. Enlarged view of the of the *iR*-corrected LSV curves of Ni_{1-x}Mn_x LDH thin film electrodes.

Table S1. Estimated OER parameters of the Ni_{1-x}Mn_x LDH thin film electrodes in terms of the overpotential at different current densities and Tafel slopes.

Catalysts	Overpotential (mV)			Tafel Slope mV dec ⁻¹
	50 mA cm ⁻²	100 mA cm ⁻²	200 mA cm ⁻²	
Ni_{0.85}Mn_{0.15}	336	367	410	149
Ni_{0.75}Mn_{0.25}	277	315	350	138
Ni_{0.65}Mn_{0.35}	253	299	342	130
Ni_{0.50}Mn_{0.50}	268	310	359	134
Ni_{0.25}Mn_{0.75}	429	460	484	142

**Figure S6.** SEM images of the best performing Ni_{0.65}Mn_{0.35} catalyst before and after stability test.

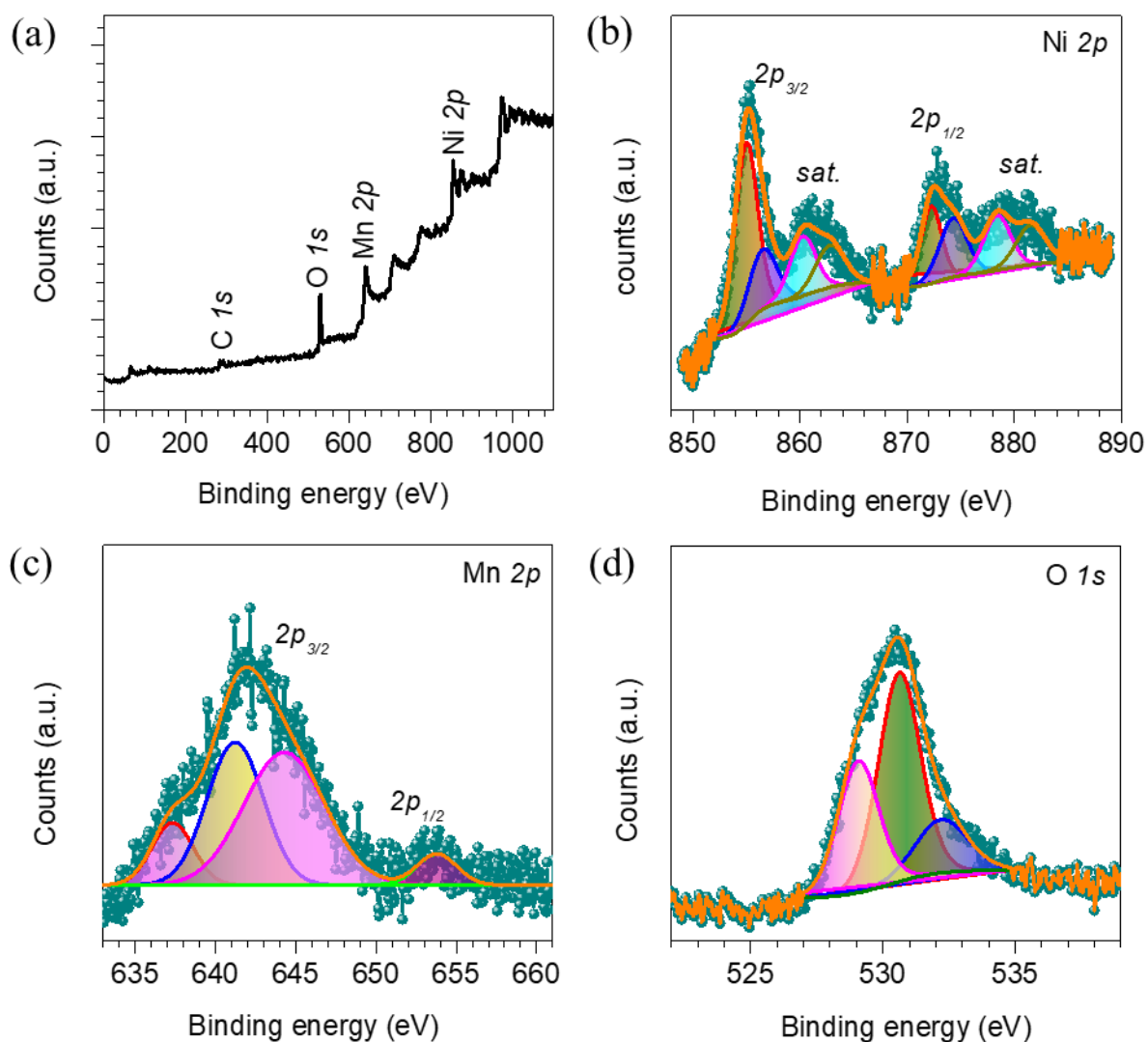


Figure S7. X-ray photoelectron spectroscopy data of the best performing $\text{Ni}_{0.65}\text{Mn}_{0.35}$ thin film electrode after long term OER test of 20 hours. (a) survey spectra indicating presence of Ni, Mn, C and O in the catalysts, deconvoluted spectra of the (b) Ni 2p, (c) Mn 2p, (d) O 1s.

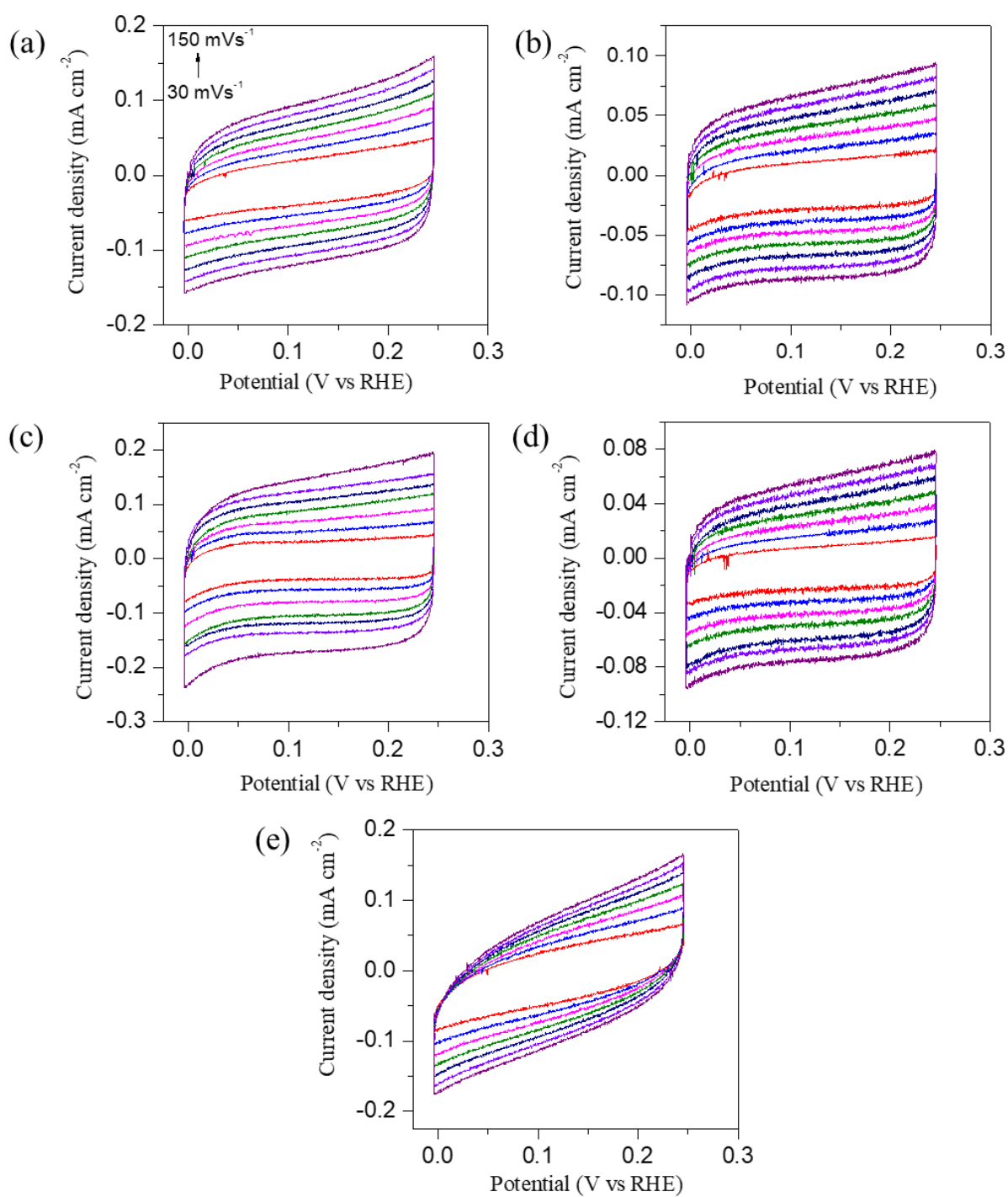


Figure S8. CV curves recorded in the non-Faradaic voltage region in 1 M KOH electrolyte at different scan rates of 30, 50, 70, 90, 110, 130 and 150 mV s^{-1} . (a) $\text{Ni}_{0.85}\text{Mn}_{0.15}$, (b) $\text{Ni}_{0.75}\text{Mn}_{0.25}$, (c) $\text{Ni}_{0.65}\text{Mn}_{0.35}$, (d) $\text{Ni}_{0.50}\text{Mn}_{0.50}$ and (e) $\text{Ni}_{0.25}\text{Mn}_{0.75}$.

Table S2. Double layer capacitance and ECSA of the $\text{Ni}_{1-x}\text{Mn}_x$ LDH thin film electrodes estimated from the plot of the scan rate (mVs^{-1}) versus current density (mAcm^{-2}).

Sample	Double-Layer Capacitances (mF cm^{-2})	ECSA (cm^2)
$\text{Ni}_{0.85}\text{Mn}_{0.15}$	0.60	15.00
$\text{Ni}_{0.75}\text{Mn}_{0.25}$	0.49	12.25
$\text{Ni}_{0.65}\text{Mn}_{0.35}$	0.93	23.25
$\text{Ni}_{0.50}\text{Mn}_{0.50}$	0.39	9.75
$\text{Ni}_{0.25}\text{Mn}_{0.75}$	0.36	9.00

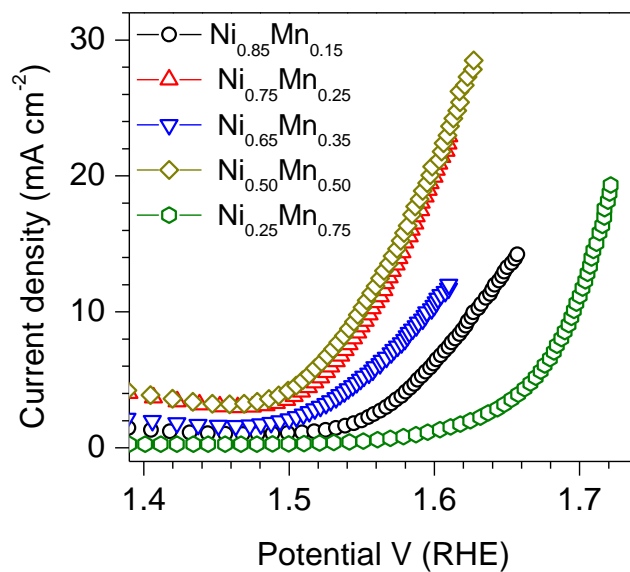


Figure S9. iR -corrected LSV curves of the $\text{Ni}_{1-x}\text{Mn}_x$ LDH thin film electrodes normalized with the ECSA values to know its intrinsic catalytic activity.

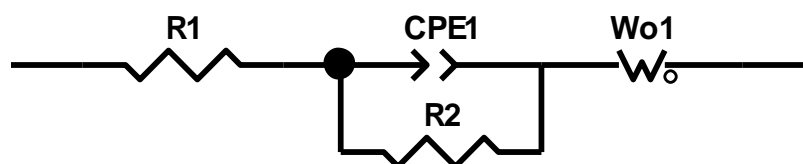


Figure S10. Equivalent circuit diagram used to fit the Nyquist plots to estimate solution resistance ($R1$), charge transfer resistance ($R2$), Warburg impedance (Wo) and constant phase element (CPE).

Table S3. EIS parameters of the Ni_{1-x}Mn_x LDH thin film electrode estimated after fitting of the Nyquist plots.

Sample	<i>R1</i> (Ω)	<i>R2</i> Ω	<i>CPE</i>
Ni_{0.85}Mn_{0.15}	1.19	83.56	0.85
Ni_{0.75}Mn_{0.25}	1.13	11.45	0.79
Ni_{0.65}Mn_{0.35}	1.11	19.55	0.72
Ni_{0.50}Mn_{0.50}	1.12	16.24	0.85
Ni_{0.25}Mn_{0.75}	1.08	22.68	0.63